

0039-7292-2 DIV

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

:

KAORI UMEZAWA, ET AL.

: GROUP UNIT:

SERIAL NO: NEW DIV. APPLN.

:

FILED: HEREWITH

: EXAMINER:

FOR: SUBSTRATE HAVING SHALLOW
TRENCH ISOLATION AND METHOD
OF MANUFACTURING THE SAME

:

PRELIMINARY AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS
Washington, D.C. 20231

SIR:

Prior to initial examination on the merits, please amend the above-identified application
as follows:

IN THE CLAIMS

Please cancel Claims 1-8 without prejudice or disclaimer.

REMARKS

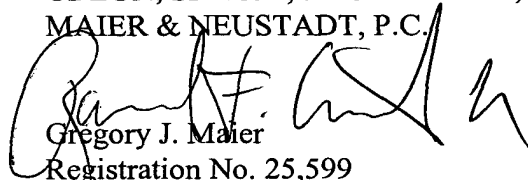
Favorable consideration of this application is respectfully requested.

2/Pre Amdt
Q
8/27/99
Dm

Claims 9-23 are presently active in this application. Original Claims 1-8 have been canceled without prejudice or disclaimer. An early and favorable examination on the merits of Claims 9-23 is respectfully requested.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
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